

Electronic Supplementary Information for:

Preparation of Amino-Substituted Anthraquinone: Study of the Intersystem Crossing and Application as Efficient Photoinitiators for Photopolymerization

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1. NMR and HRMS Spectra

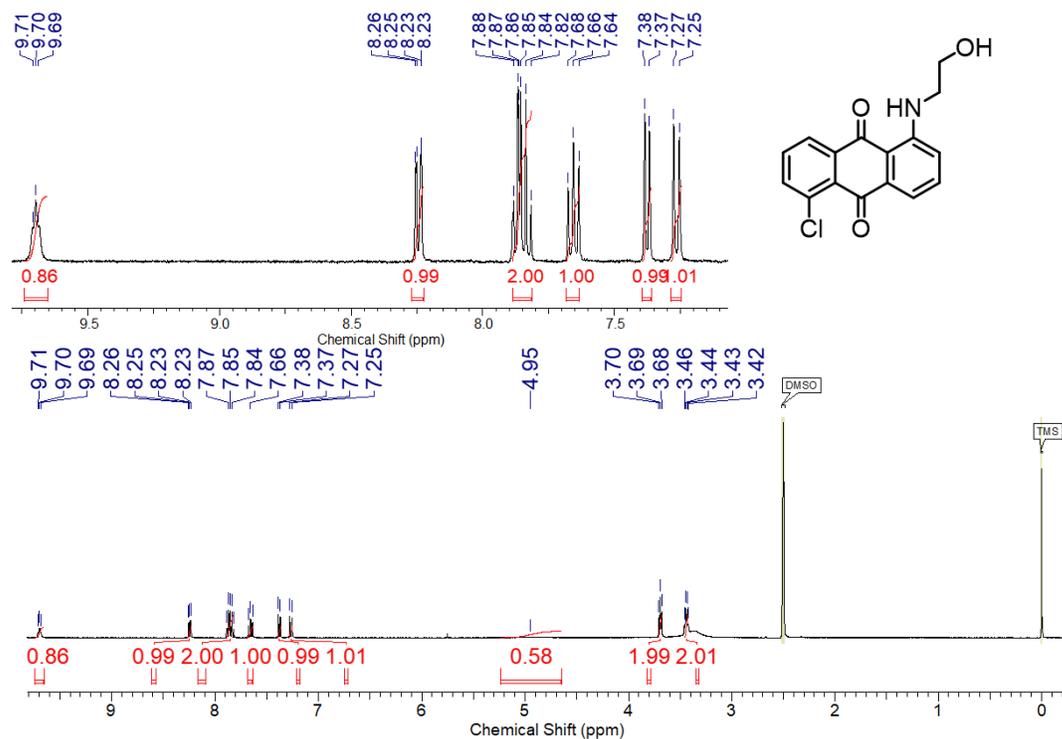


Figure S1. ¹H NMR spectrum of compound AQ-NH-OH-5-Cl (DMSO-d₆, 400 MHz).

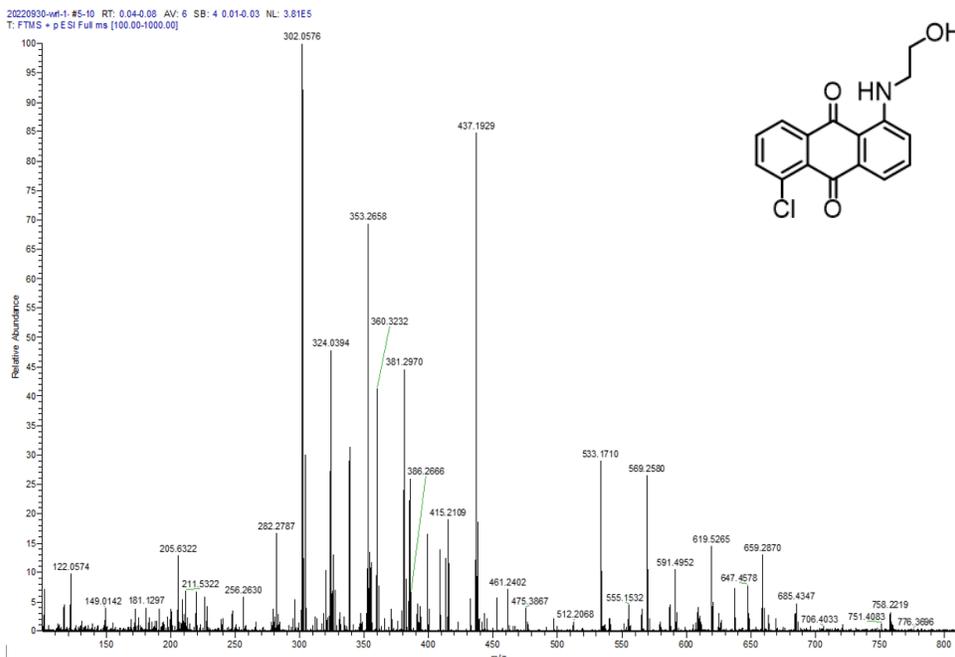


Figure S2. HRMS ESI⁺ of compound AQ-NH-OH-5-Cl.

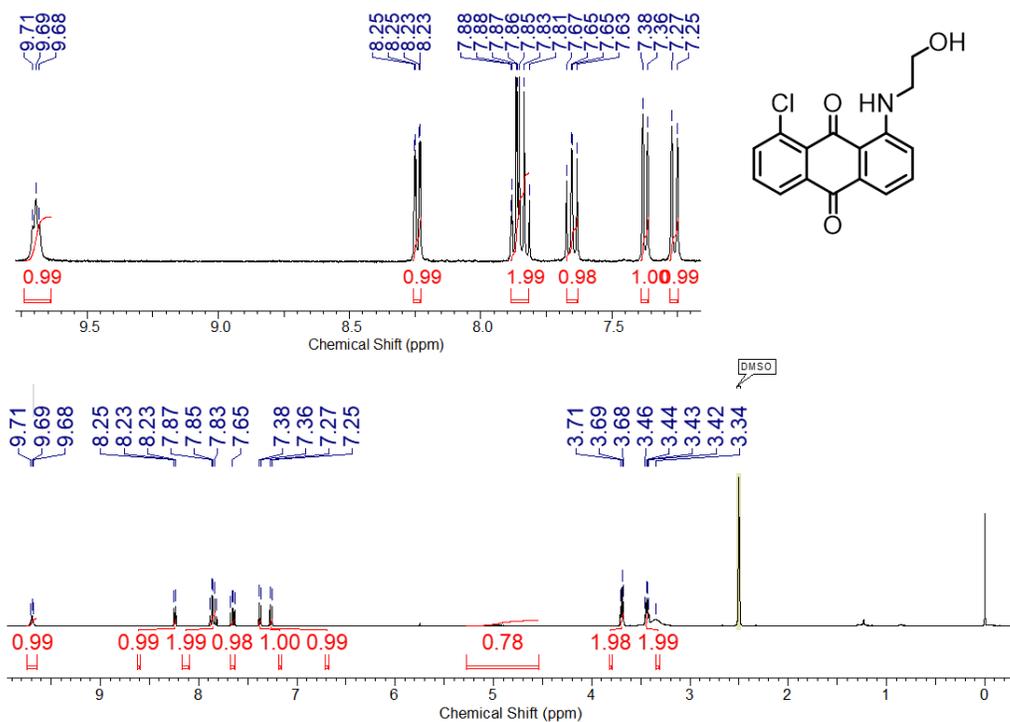


Figure S3. ¹H NMR spectrum of compound AQ-NH-OH-8-Cl (DMSO-*d*₆, 400 MHz).

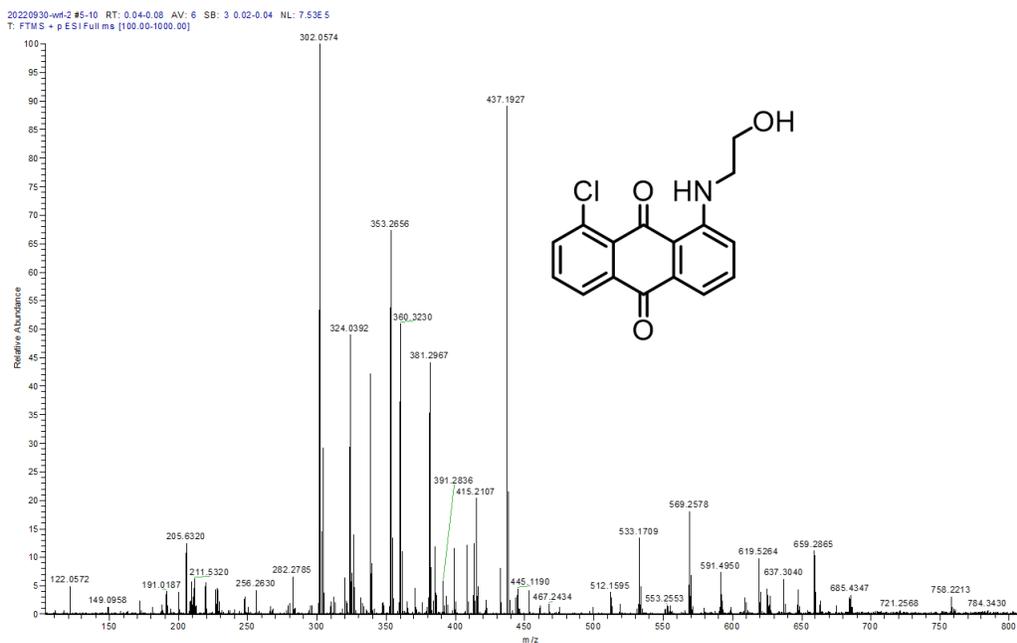


Figure S4. HRMS ESI⁺ of compound AQ-NH-OH-8-Cl.

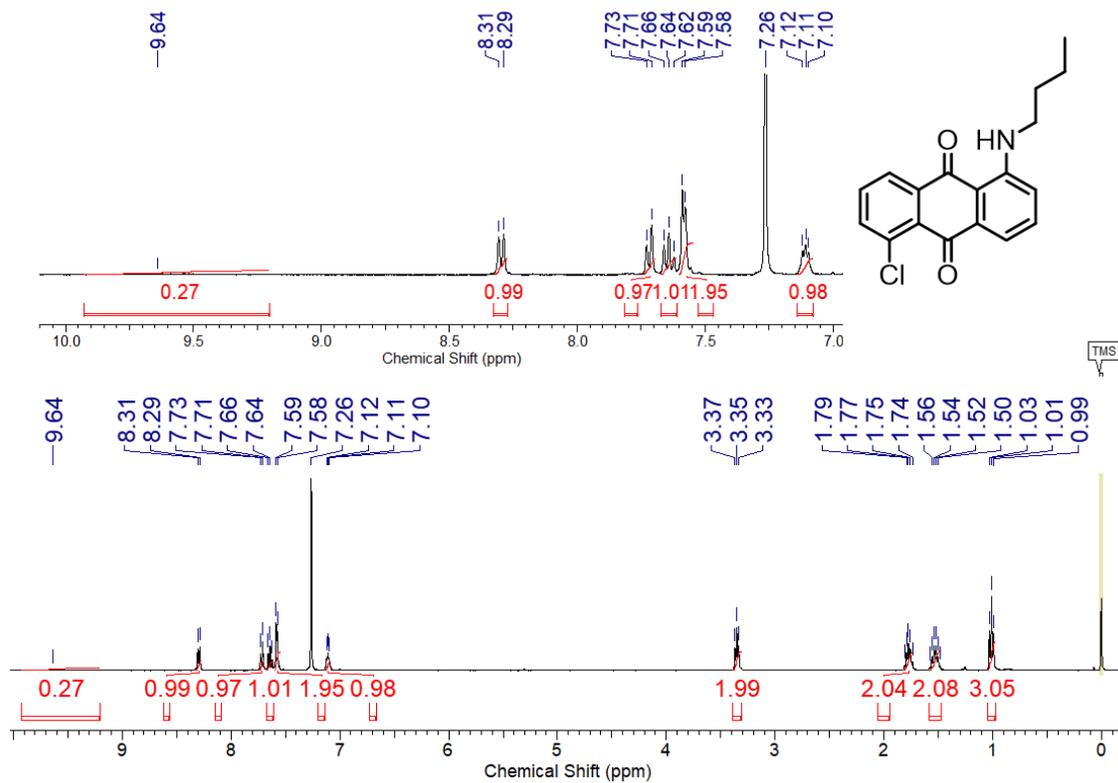


Figure S5. ^1H NMR spectrum of compound AQ-NH-5-Cl (CDCl_3 , 400 MHz).

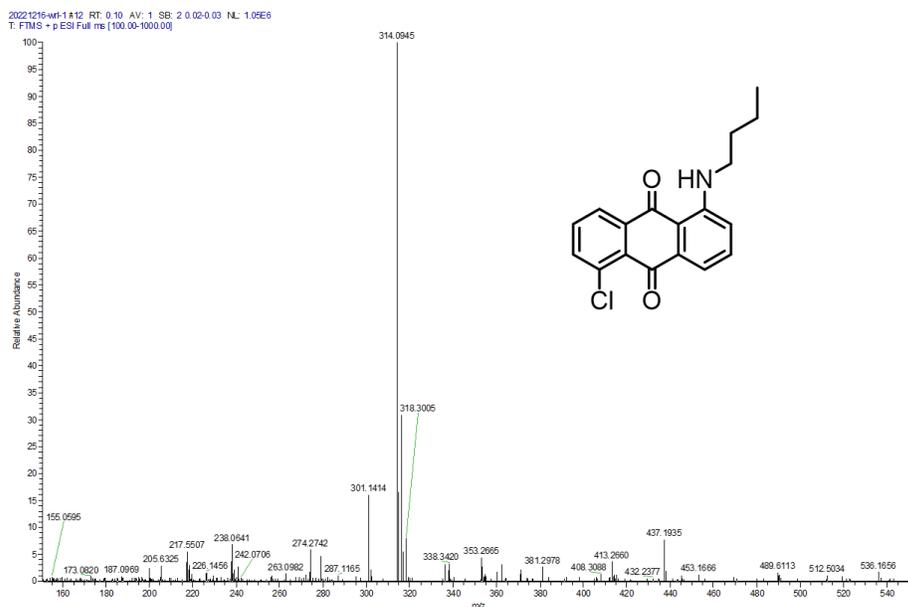


Figure S6. HRMS ESI⁺ of compound AQ-NH-5-Cl.

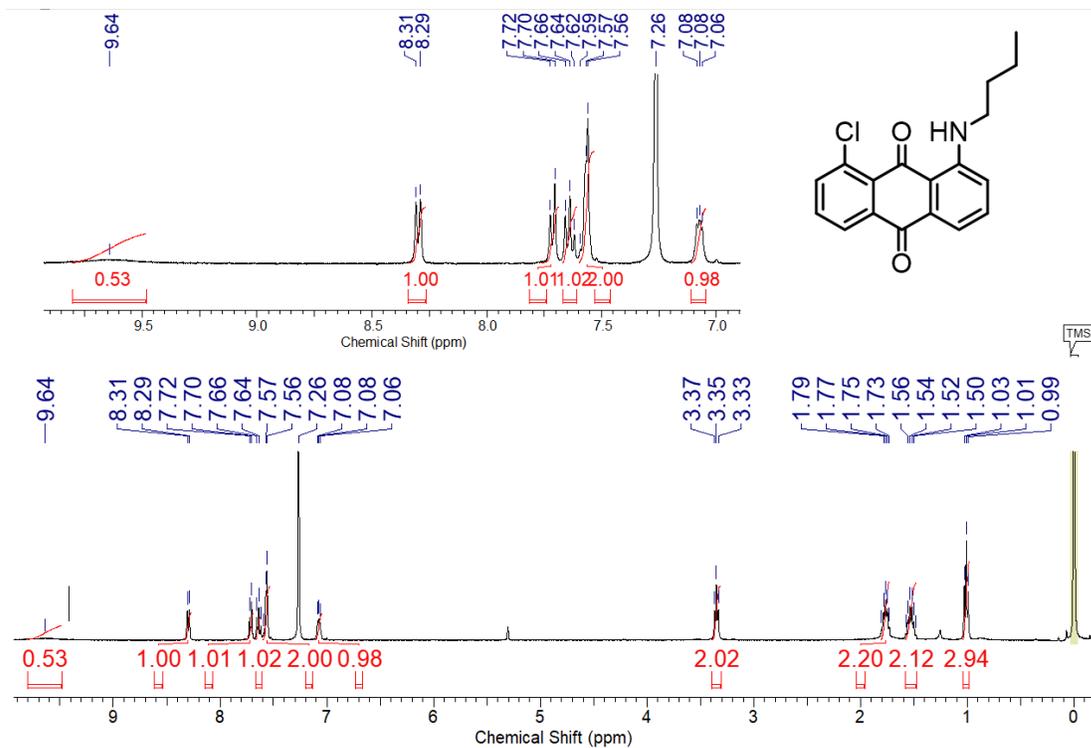


Figure S7. ^1H NMR spectrum of compound **AQ-NH-8-Cl** (CDCl_3 , 400 MHz).

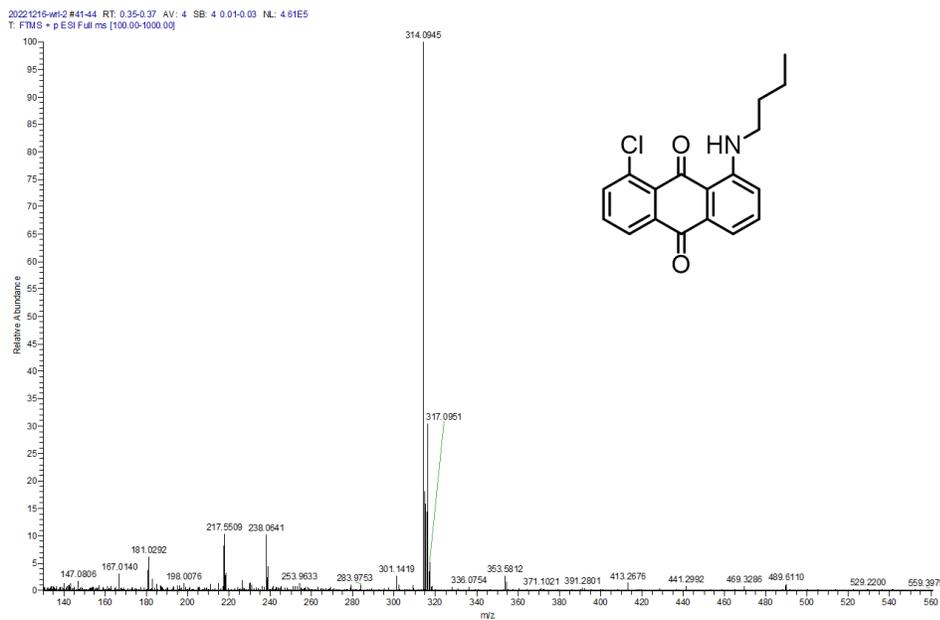


Figure S8. HRMS ESI⁺ of compound **AQ-NH-8-Cl**.

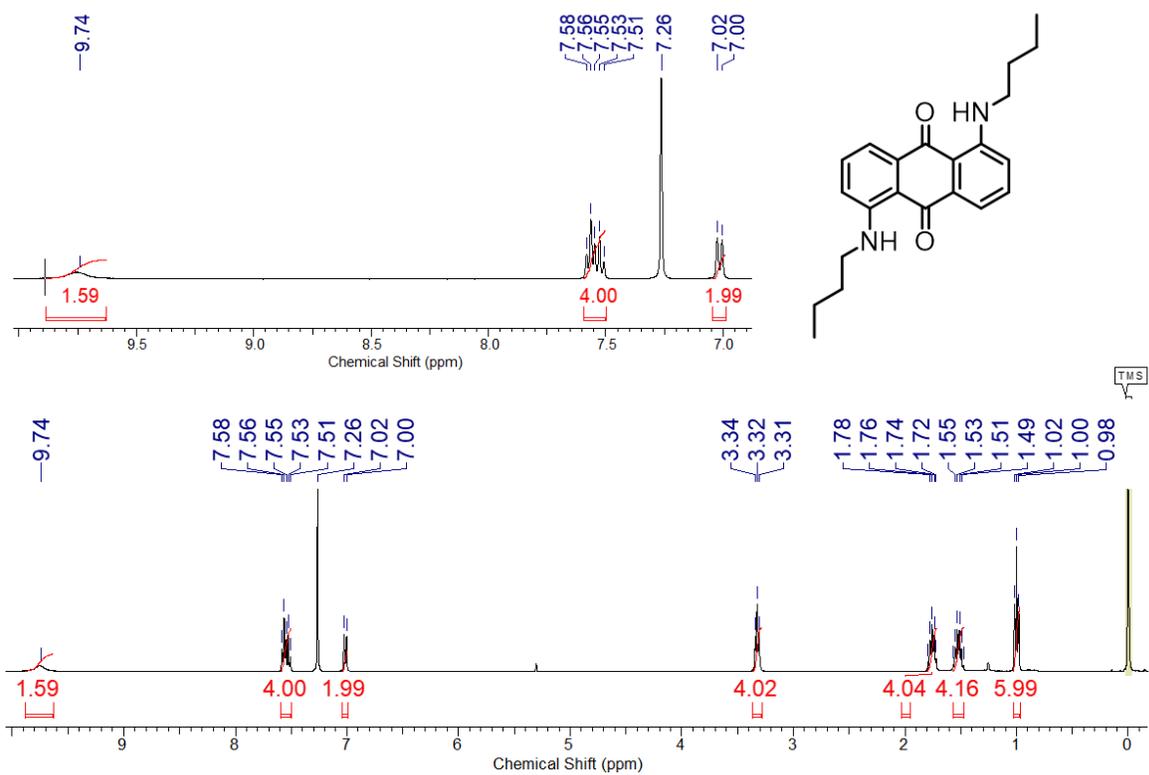


Figure S9. ^1H NMR spectrum of compound AQ-1,5-NH (CDCl_3 , 400 MHz).

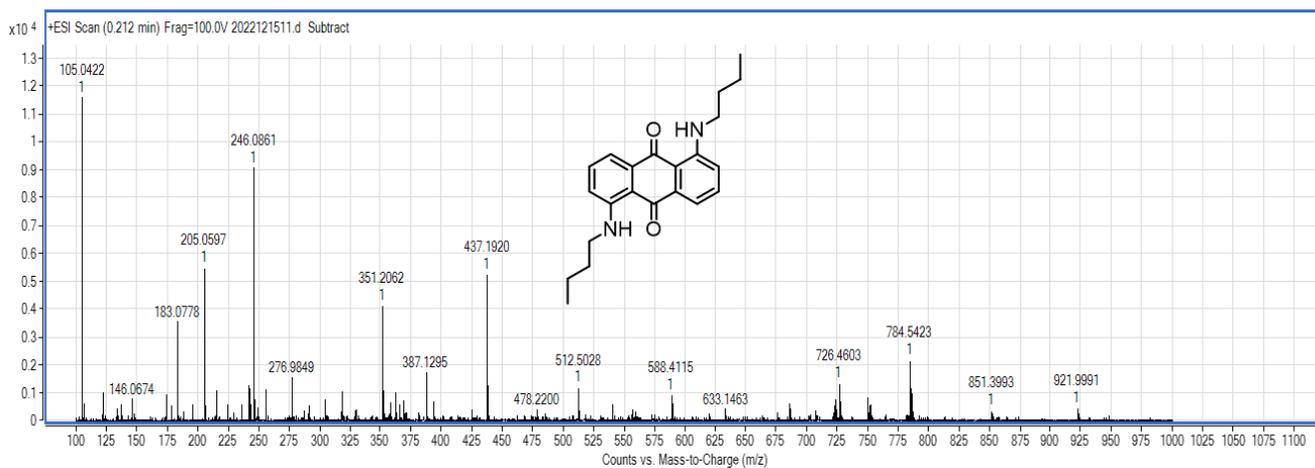


Figure S10. HRMS ESI $^+$ of compound AQ-1,5-NH.

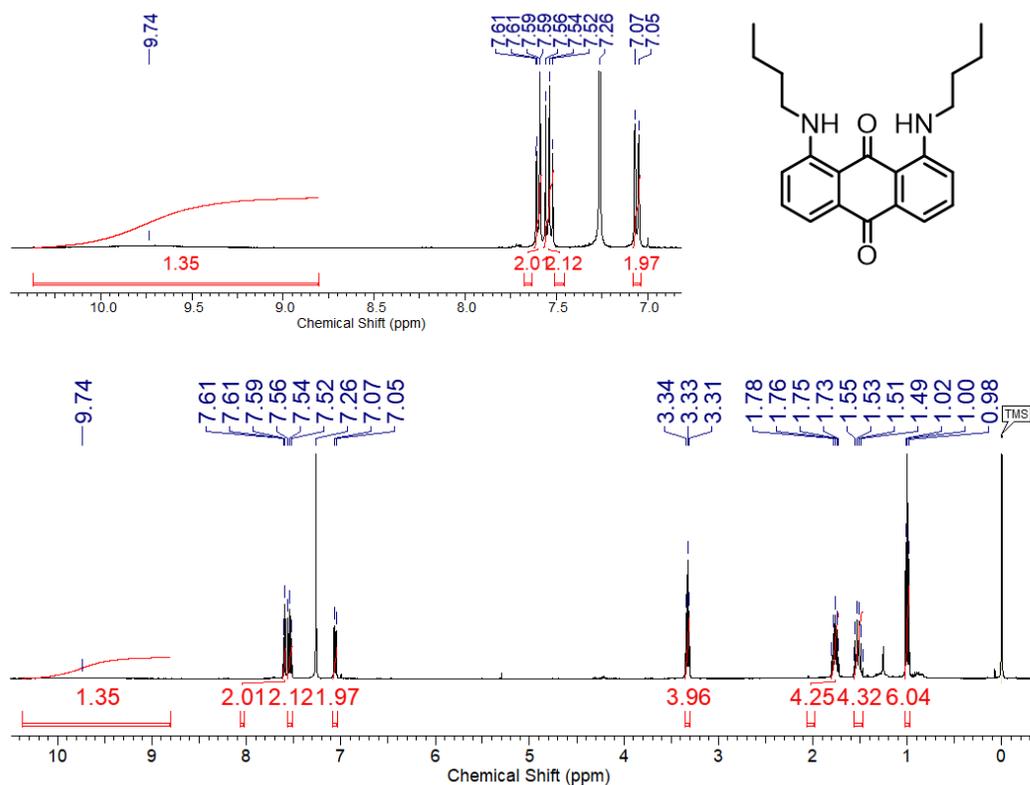


Figure S11. ^1H NMR spectrum of compound AQ-1,8-NH (CDCl_3 , 400 MHz).

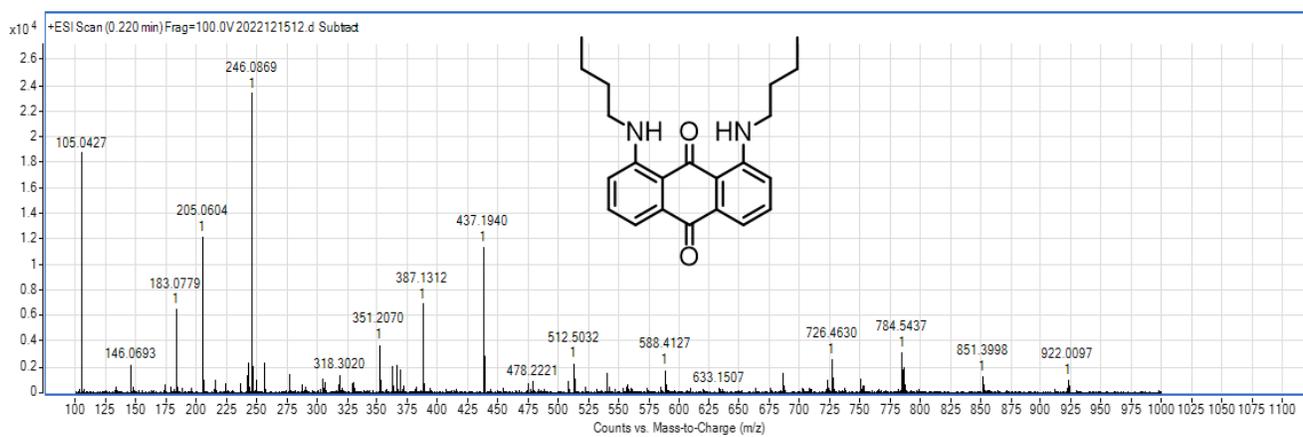


Figure S12. HRMS ESI $^+$ of compound AQ-1,5-NH.

2. Steady State UV–Vis Absorption and Luminescence Spectra

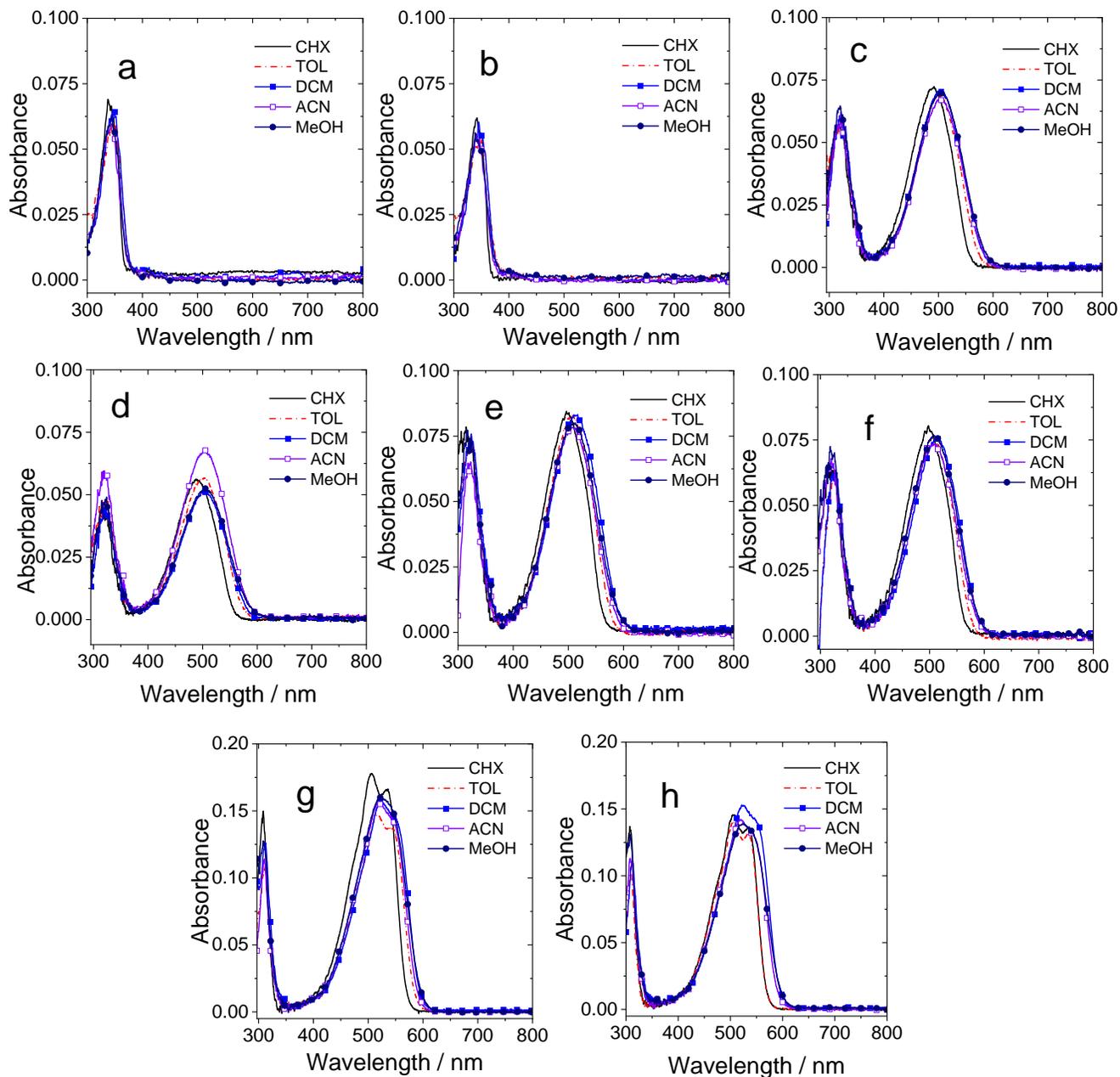


Figure S13. UV–vis absorption spectra of (a) AQ-1,5-Cl₂; (b) AQ-1,8-Cl₂; (c) AQ-NH-OH-5-Cl; (d) AQ-NH-OH-8-Cl; (e) AQ-NH-5-Cl; (f) AQ-NH-8-Cl; (g) AQ-1,5-NH and (h) AQ-1,8-NH in different solvents. $c = 1.0 \times 10^{-5}$ M, 20 °C.

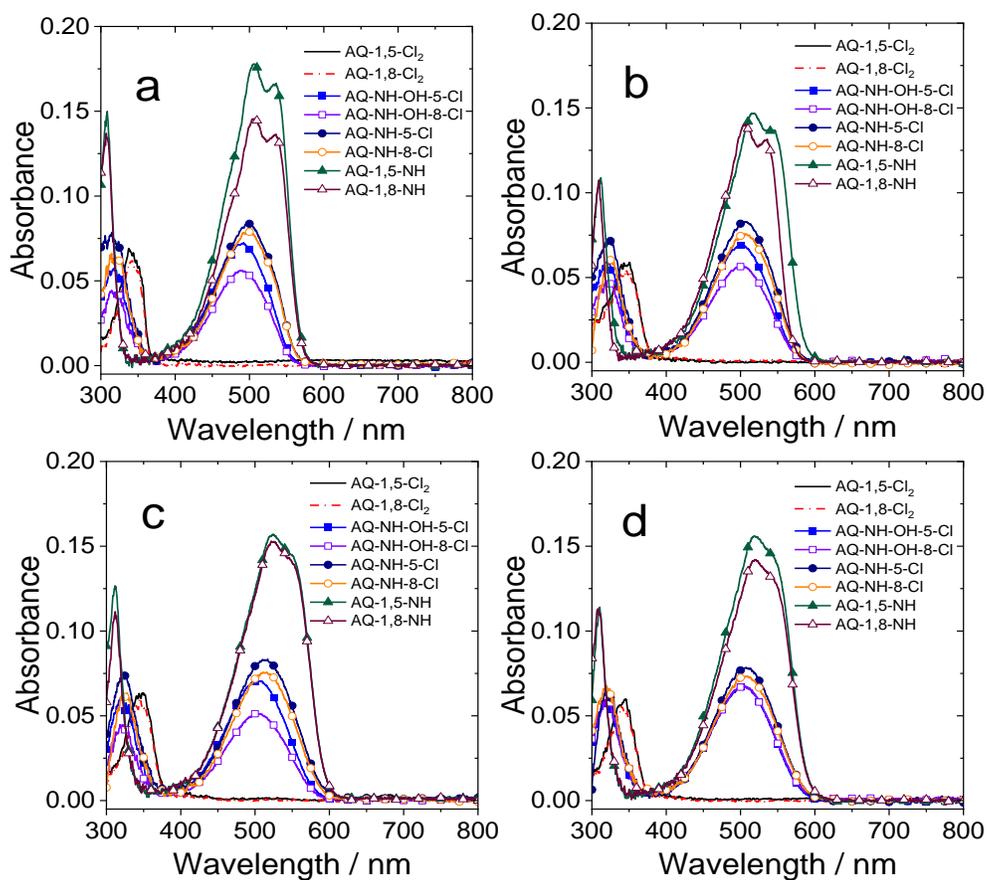


Figure S14. UV–vis absorption spectra of **compounds** in (a) cyclohexane (CHX); (b) toluene (TOL); (c) dichloromethane (DCM); (d) acetonitrile (ACN). $c = 1.0 \times 10^{-5}$ M, 20 °C.

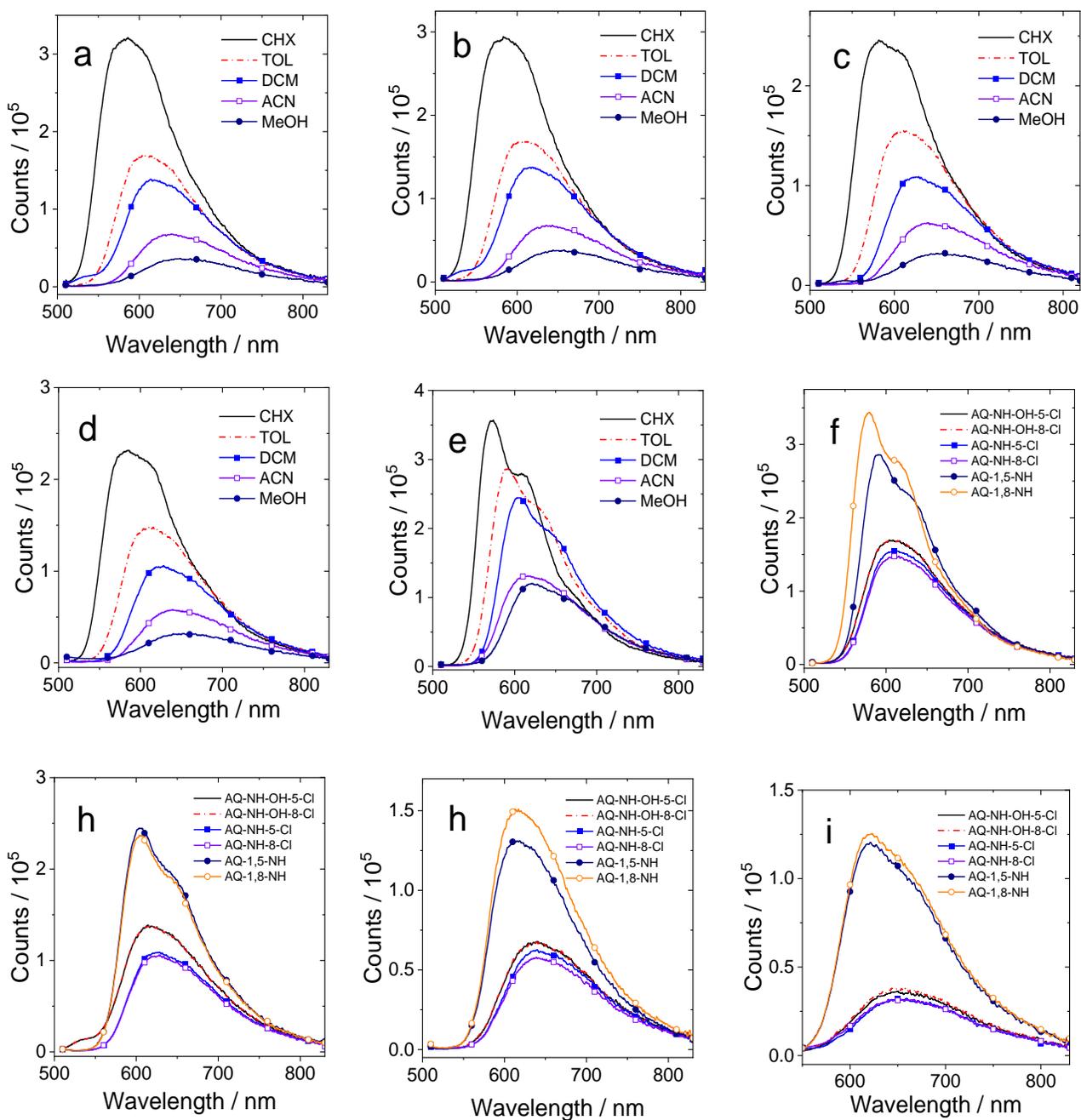


Figure S15. Fluorescence emission spectra of (a) **AQ-NH-OH-5-Cl**; (b) **AQ-NH-OH-8-Cl**; (c) **AQ-NH-5-Cl**; (d) **AQ-NH-8-Cl** and (e) **AQ-1,5-NH** in different solvents. Fluorescence emission spectra of compounds in (f) toluene (TOL); (g) dichloromethane (DCM); (h) acetonitrile (ACN); (i) Methanol (MeOH). Optically-matched solutions were used. $A = 0.1$, $\lambda_{\text{ex}} = 500$ nm, 20 °C.

3. Photobleaching and photopolymerization

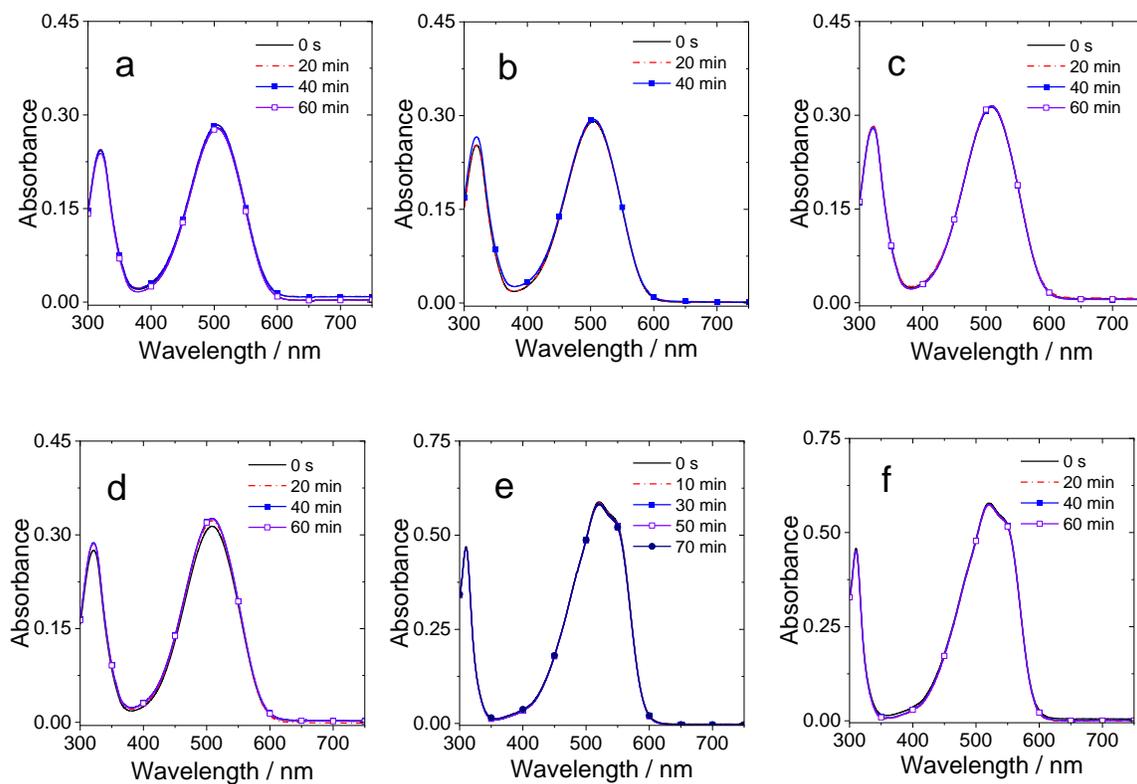


Figure S16. Steady state photolysis of (a) **AQ-NH-OH-5-Cl**; (b) **AQ-NH-OH-8-Cl**; (c) **AQ-NH-5-Cl**; (d) **AQ-NH-8-Cl**; (e) **AQ-1,5-NH** and (f) **AQ-1,8-NH** in deaerated acetonitrile upon the xenon lamp exposure; c [photosensitizer] = 5.0×10^{-5} M. UV-vis spectra recorded at different irradiation times. unfiltered white light intensity = 30 mW cm^{-2}

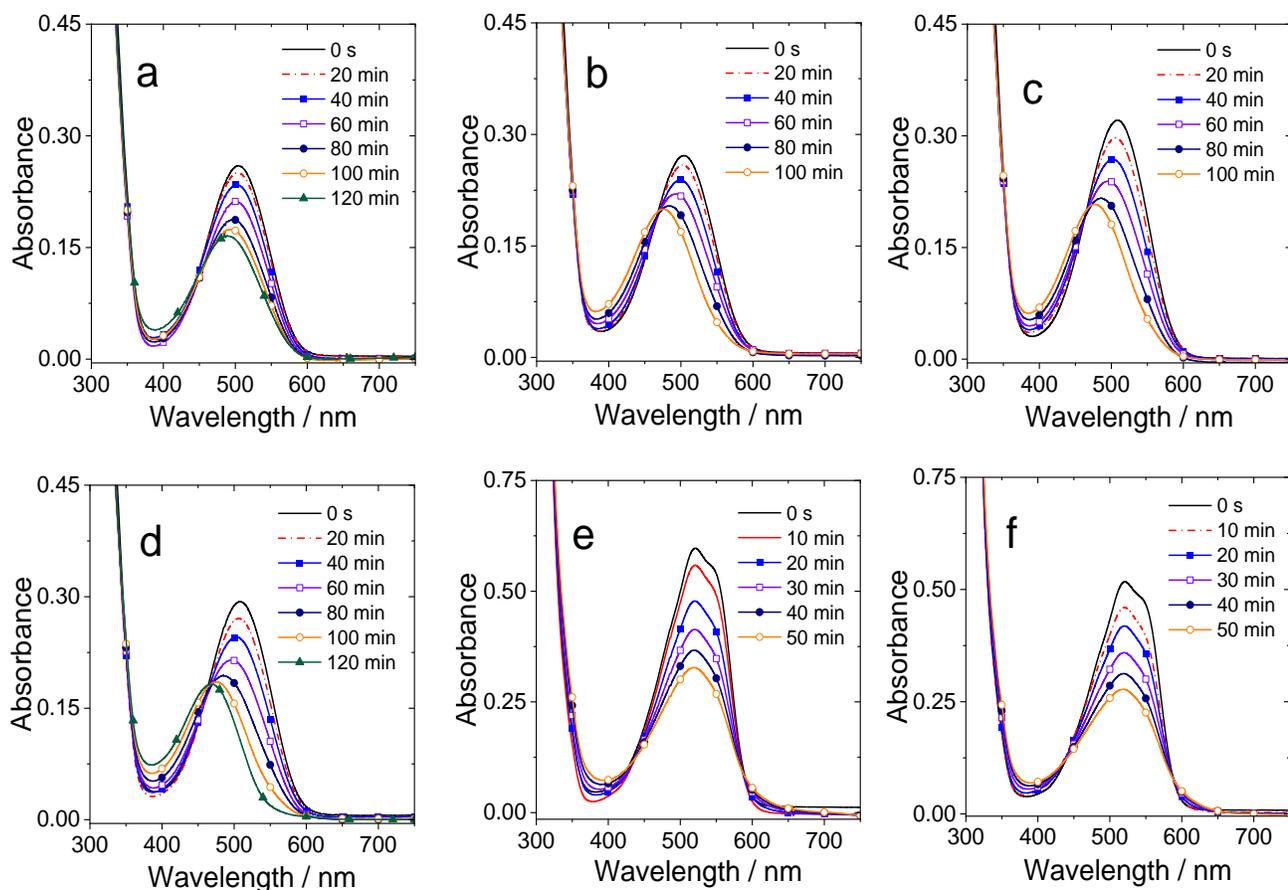


Figure S17. Steady state photolysis of (a) **AQ-NH-OH-5-Cl/DPI**; (b) **AQ-NH-OH-8-Cl/DPI**; (c) **AQ-NH-5-Cl/DPI**; (d) **AQ-NH-8-Cl/DPI**; (e) **AQ-1,5-NH/DPI** and (f) **AQ-1,8-NH/DPI** in deaerated acetonitrile upon the xenon lamp exposure; c [photosensitizer] = 5.0×10^{-5} M , c [Iod] = 30 mM. Uv-vis spectra recorded at different irradiation times. unfiltered white light intensity = 30 mW cm^{-2}

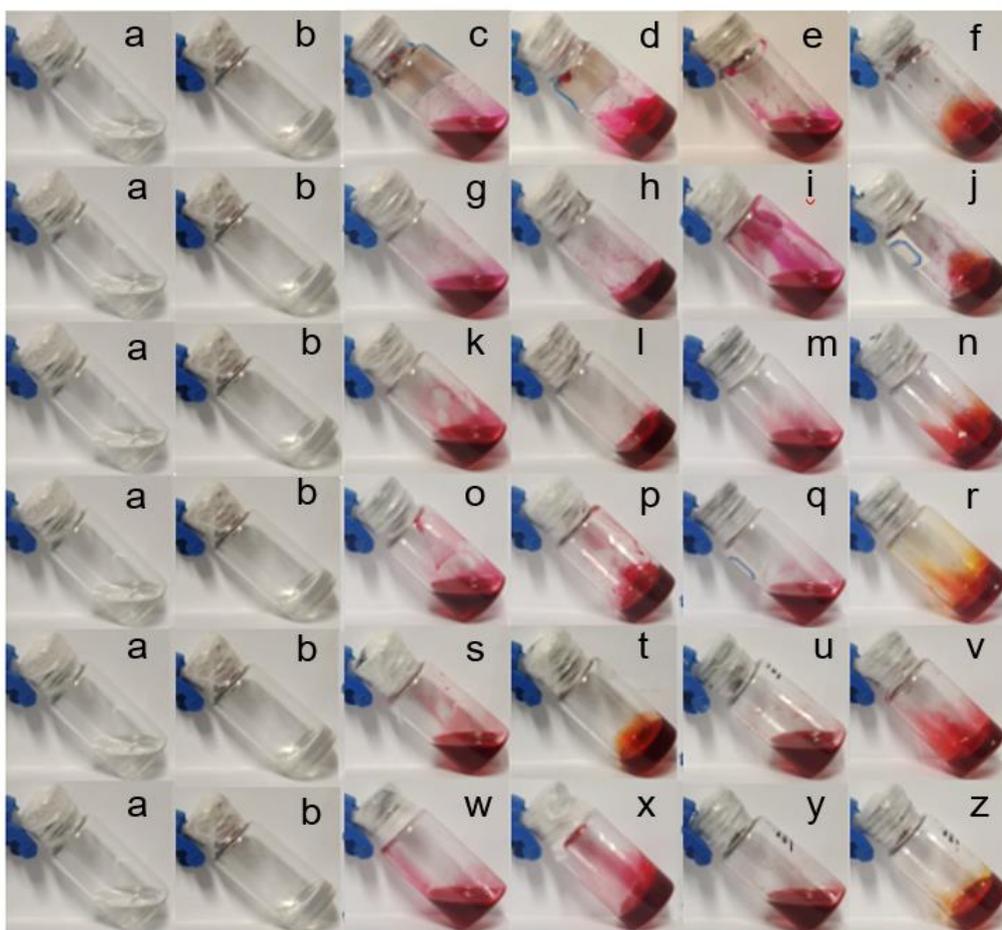


Figure S18. The photopolymerization of PETA under N_2 upon exposure to a 35 W Xenon lamp (unfiltered white light intensity = 200 mW cm^{-2}). In the presence of (a) TEA, (c) AQ-1,5-NH, (e) AQ-1,5-NH/TEA, (g) AQ-1,8-NH, (i) AQ-1,8-NH/TEA, (k) AQ-NH-5-Cl, (m) AQ-NH-5-Cl/TEA, (o) AQ-NH-8-Cl, (q) AQ-NH-8-Cl/TEA, (s) AQ-NH-OH-5-Cl, (u) AQ-NH-OH-5-Cl/TEA, (w) AQ-NH-OH-8-Cl and (y) AQ-NH-OH-8-Cl/TEA. The photopolymerization of PETA under N_2 upon exposure to a 35 W Xenon lamp (unfiltered white light intensity = 200 mW cm^{-2}). In the presence of (b) TEA, (d) AQ-1,5-NH, (f) AQ-1,5-NH/TEA, (h) AQ-1,8-NH, (j) AQ-1,8-NH/TEA, (l) AQ-NH-5-Cl, (n) AQ-NH-5-Cl/TEA, (p) AQ-NH-8-Cl, (r) AQ-NH-8-Cl/TEA, (t) AQ-NH-OH-5-Cl, (v) AQ-NH-OH-5-Cl/TEA, (x) AQ-NH-OH-8-Cl and (z) AQ-NH-OH-8-Cl/TEA. (photosensitizer: 0.3 wt%; TEA: 6.2 wt%)

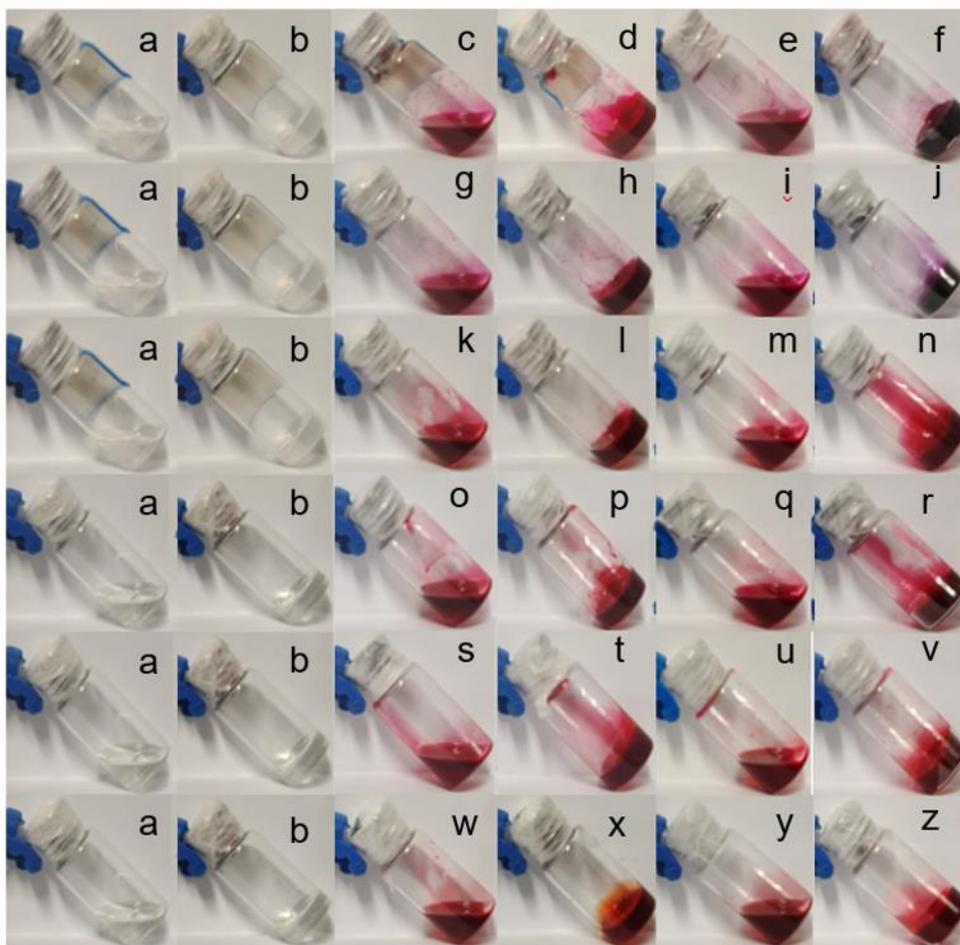


Figure S19. The photopolymerization of PETA under N_2 before a 35 W Xenon lamp irradiation (unfiltered white light intensity = 200 mW cm^{-2}). In the presence of (a) **DPI**, (c) **AQ-1,5-NH**, (e) **AQ-1,5-NH/DPI**, (g) **AQ-1,8-NH**, (i) **AQ-1,8-NH/DPI**, (k) **AQ-NH-5-Cl**, (m) **AQ-NH-5-Cl/DPI**, (o) **AQ-NH-8-Cl**, (q) **AQ-NH-8-Cl/DPI**, (s) **AQ-NH-OH-5-Cl**, (u) **AQ-NH-OH-5-Cl/DPI**, (w) **AQ-NH-OH-8-Cl** and (y) **AQ-NH-OH-8-Cl/DPI**. The photopolymerization of PETA under N_2 after a 35 W Xenon lamp irradiation (unfiltered white light intensity = 200 mW cm^{-2}). In the presence of (b) **DPI**, (d) **AQ-1,5-NH**, (f) **AQ-1,5-NH/DPI**, (h) **AQ-1,8-NH**, (j) **AQ-1,8-NH/DPI**, (l) **AQ-NH-5-Cl**, (n) **AQ-NH-5-Cl/DPI**, (p) **AQ-NH-8-Cl**, (r) **AQ-NH-8-Cl/DPI**, (t) **AQ-NH-OH-5-Cl**, (v) **AQ-NH-OH-5-Cl/DPI**, (x) **AQ-NH-OH-8-Cl** and (z) **AQ-NH-OH-8-Cl/DPI**. (photosensitizer: 0.3 wt%; DPI : 6.2 wt%).

Table S1. The photopolymerization of PETA obtained upon exposure to the Xeon lamp in the presence of anthraquinone derivatives based PISs^a

PISs	The polymerization time of PETA/min
<i>_b</i>	<i>_c</i>
DPI	7
TEA	12
AQ-1,5-NH	8
AQ-1,5-NH/DPI	1
AQ-1,5-NH/TEA	5
AQ-1,8-NH	6
AQ-1,8-NH/DPI	0.6
AQ-1,8-NH/TEA	4
AQ-NH-5-Cl	10
AQ-NH-5-Cl/DPI	2.8
AQ-NH-5-Cl/TEA	7
AQ-NH-8-Cl	10
AQ-NH-8-Cl/DPI	3.5
AQ-NH-8-Cl/TEA	5
AQ-NH-OH-5-Cl	21
AQ-NH-OH-5-Cl/DPI	3.7
AQ-NH-OH-5-Cl/TEA	18
AQ-NH-OH-8-Cl	30
AQ-NH-OH-8-Cl/DPI	4.7
AQ-NH-OH-8-Cl/TEA	21

^a The photopolymerization of PETA under N₂ in the presence of anthraquinone derivatives based PISs (photosensitizer: 0.3 wt%; DPI or TEA: 6.2 wt%) obtained upon exposure to the Xeon lamp, unfiltered white light intensity = 200 mW cm⁻². ^b In the absence of photosensitizer or coinitiator. ^c Can't polymerization.

4. DFT computation

Table S2. Electronic Excitation Energies (eV) and Corresponding Oscillator Strengths (f), Main Configurations, and CI Coefficients of the Low-Lying Electronic Excited States of AQ-1,5-NH in gas phase were Presented. All Parameters were Calculated by B3LYP/6-31G(d). Base on the optimized ground state geometry.

	State	Energy ^a	<i>f</i> ^b	CI ^c	Composition ^d
AQ-1,5-NH	S ₁	2.53 eV/489 nm	0.24	0.70	H→L
	S ₇	4.25 eV/292 nm	0.18	0.69	H-1→L+1
	S ₈	4.47 eV/277 nm	0.08	0.66	H-5→L
	T ₁	1.86 eV/666 nm	0.00	0.70	H→L
	T ₂	1.87 eV/664 nm	0.00	0.70	H-1→L
	T ₃	2.71 eV/458 nm	0.00	0.69	H-2→L
	T ₄	2.91 eV/426 nm	0.00	0.55	H-5→L
	T ₅	2.94 eV/421 nm	0.00	0.57	H-3→L

^aOnly the selected low lying excited states are presented. ^bOscillator strengths. ^cCI coefficients are in absolute values. ^dOnly the main configurations are presented.

Table S3. Electronic Excitation Energies (eV) and Corresponding Oscillator Strengths (f), Main Configurations, and CI Coefficients of the Low-Lying Electronic Excited States of AQ-1,8-NH in gas phase were Presented. All Parameters were Calculated by B3LYP/6-31G(d). Base on the optimized ground state geometry.

	State	Energy ^a	f^b	CI ^c	Composition ^d
AQ-1,8-NH	S ₁	2.40 eV/517 nm	0.21	0.70	H→L
	S ₆	4.10 eV/303 nm	0.10	0.67	H→L+1
	S ₇	4.33 eV/286 nm	0.06	0.66	H-1→L+1
	T ₁	1.80 eV/691 nm	0.00 ^g	0.70	H→L
	T ₂	1.93 eV/643 nm	0.00 ^g	0.69	H-1→L
	T ₃	2.56 eV/485 nm	0.00 ^g	0.67	H-2→L
	T ₄	2.91 eV/425 nm	0.00 ^g	0.54	H-3→L
	T ₅	2.94 eV/421 nm	0.00 ^g	0.55	H-5→L

^aOnly the selected low lying excited states are presented. ^bOscillator strengths. ^cCI coefficients are in absolute values. ^dOnly the main configurations are presented.

Table S4. Electronic Excitation Energies (eV) and Corresponding Oscillator Strengths (f), Main Configurations, and CI Coefficients of the Low-Lying Electronic Excited States of AQ-NH-5-Cl in gas phase were Presented. All Parameters were Calculated by B3LYP/6-31G(d). Base on the optimized ground state geometry.

	State	Energy ^a	<i>f</i> ^b	CI ^c	Composition ^d
AQ-NH-5-Cl	S ₁	2.56 eV/484 nm	0.13	0.70	H→L
	S ₄	3.63 eV/341 nm	0.05	0.68	H-2→L
	S ₆	3.86 eV/321 nm	0.06	0.53	H→L+1
	T ₁	1.80 eV/687 nm	0.00 ^g	0.70	H→L
	T ₂	2.38 eV/520 nm	0.00 ^g	0.67	H-1→L
	T ₃	2.84 eV/437 nm	0.00 ^g	0.39	H-3→L
	T ₄	2.92 eV/425 nm	0.00 ^g	0.67	H-4→L
	T ₅	3.03 eV/409 nm	0.00 ^g	0.46	H-2→L

^aOnly the selected low lying excited states are presented. ^bOscillator strengths. ^cCI coefficients are in absolute values. ^dOnly the main configurations are presented.

Table S5. Electronic Excitation Energies (eV) and Corresponding Oscillator Strengths (f), Main Configurations, and CI Coefficients of the Low-Lying Electronic Excited States of AQ-NH-8-Cl in gas phase were Presented. All Parameters were Calculated by B3LYP/6-31G(d). Base on the optimized ground state geometry.

	State	Energy ^a	<i>f</i> ^b	CI ^c	Composition ^d
AQ-NH-8-Cl	S ₁	2.52 eV/492 nm	0.12	0.70	H→L
	S ₄	3.64 eV/341 nm	0.04	0.67	H-2→L
	S ₆	3.84 eV/323 nm	0.05	0.50	H-4→L
	T ₁	1.77 eV/700 nm	0.00	0.70	H→L
	T ₂	2.49 eV/497 nm	0.00	0.66	H-1→L
	T ₃	2.77 eV/448 nm	0.00	0.64	H-3→L
	T ₄	2.81 eV/441 nm	0.00	0.35	H-4→L
	T ₅	2.99 eV/414 nm	0.00	0.41	H-2→L

^aOnly the selected low lying excited states are presented. ^bOscillator strengths. ^cCI coefficients are in absolute values. ^dOnly the main configurations are presented.

Table S6. Electronic Excitation Energies (eV) and Corresponding Oscillator Strengths (f), Main Configurations, and CI Coefficients of the Low-Lying Electronic Excited States of AQ-NH-OH-5-Cl in gas phase were Presented. All Parameters were Calculated by B3LYP/6-31G(d). Base on the optimized ground state geometry.

	State	Energy ^a	<i>f</i> ^b	CI ^c	Composition ^d
AQ-NH-OH-5-Cl	S ₁	2.56 eV/485 nm	0.13	0.70	H→L
	S ₄	3.63 eV/341 nm	0.05	0.68	H-2→L
	S ₆	3.85 eV/322 nm	0.06	0.53	H→L+1
	T ₁	1.80 eV/689 nm	0.00	0.70	H→L
	T ₂	2.38 eV/521 nm	0.00	0.67	H-1→L
	T ₃	2.84 eV/437 nm	0.00	0.41	H-3→L
	T ₄	2.93 eV/423 nm	0.00	0.66	H-4→L
	T ₅	3.03 eV/409 nm	0.00	0.45	H-2→L

^aOnly the selected low lying excited states are presented. ^bOscillator strengths. ^cCI coefficients are in absolute values. ^dOnly the main configurations are presented.

Table S7. Electronic Excitation Energies (eV) and Corresponding Oscillator Strengths (f), Main Configurations, and CI Coefficients of the Low-Lying Electronic Excited States of AQ-NH-OH-8-Cl in gas phase are Presented. All Parameters were Calculated by B3LYP/6-31G(d). Base on the optimized ground state geometry.

	State	Energy ^a	<i>f</i> ^b	CI ^c	Composition ^d
AQ-NH-OH-8-Cl	S ₁	2.52 eV/493 nm	0.12	0.70	H→L
	S ₄	3.64 eV/340 nm	0.04	0.66	H-2→L
	S ₆	3.83 eV/324 nm	0.06	0.51	H-4→L
	T ₁	1.76 eV/703 nm	0.00	0.70	H→L
	T ₂	2.50 eV/496 nm	0.00	0.66	H-1→L
	T ₃	2.77 eV/447 nm	0.00	0.64	H-3→L
	T ₄	2.81 eV/442 nm	0.00	0.36	H-4→L
	T ₅	2.99 eV/414 nm	0.00	0.41	H-2→L

^aOnly the selected low lying excited states are presented. ^bOscillator strengths. ^cCI coefficients are in absolute values. ^dOnly the main configurations are presented.

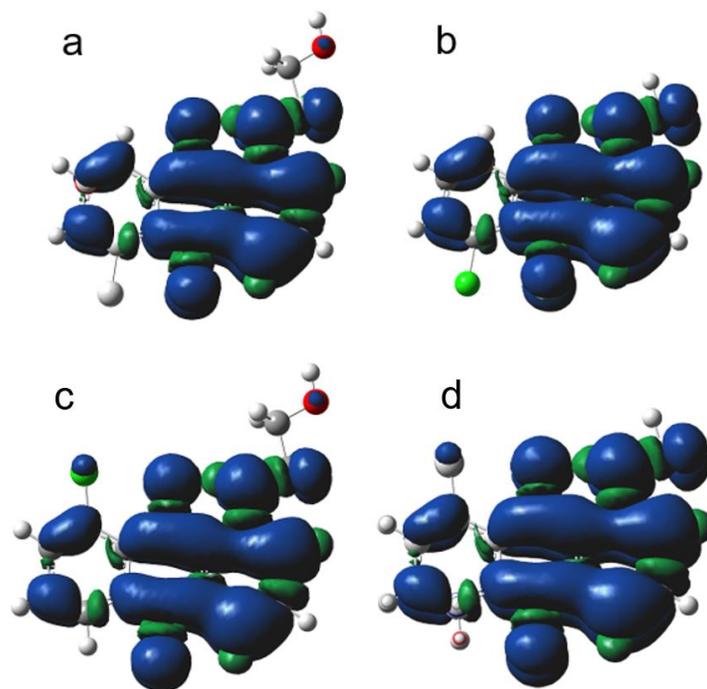


Figure S20. Electron spin density surfaces of the triplet state of (a) **AQ-NH-OH-5-Cl**, (b) **AQ-NH-5-Cl**, (c) **AQ-NH-OH-8-Cl** and (d) **AQ-NH-8-Cl** calculated by DFT (B3LYP/6-31G (d)) in vacuum with Gaussian 09. isovalue = 0.0004.